

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: HONGYU YUE

Application No.: Confirmation
No:
Filed: March 30, 2004 Group No.:
Examiner
For: METHOD AND SYSTEM FOR ADJUSTING A CHEMICAL OXIDE REMOVAL
PROCESS USING PARTIAL PRESSURE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

APPLICATION DATA SHEET
37 C.F.R. § 1.76

BIBLIOGRAPHIC DATA

1. Applicant information

First applicant: HONGYU YUE
Citizenship: USA
Residence: Austin, TX 78479

2. Correspondence information

Correspondence for this application should be addressed as follows:

Customer No.: 00909

3. Application information

Title of Invention: METHOD AND SYSTEM FOR ADJUSTING A CHEMICAL OXIDE
REMOVAL PROCESS USING PARTIAL PRESSURE

Docket number assigned to this application: 071469-0307699

Suggested Classification: Class:
Subclass:
Technology Center to which subject matter is assigned:

Total number of drawing sheets: 22

Type of application: Utility

Application is to be published. Suggested drawing figure for publication:

Secrecy order under § 5.2:

This application does not disclose subject matter of an application which is under a secrecy order pursuant to § 5.2.

4. Representative information

The following have a power of attorney or authorization of agent in this application:

Customer No.: 00909

5. Assignee information

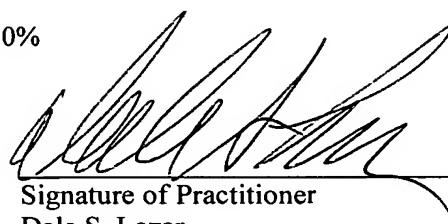
The assignee(s) of this application is/are:

Tokyo Electron Limited
3-6, Akasaka 5-chome, Minato-ku
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JAPAN

Extent of interest of assignee in application: 100%

Date: March 30, 2004

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